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APPLICATION NO.	F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/644,957	10/644,957 08/21/2003		Gordon Bease	071469-0305396	7598	
909	7590	02/01/2006		EXAMINER		
PILLSBUR P.O. BOX 10		THROP SHAW	ARANCIBIA, MAUI	ARANCIBIA, MAUREEN GRAMAGLIA		
MCLEAN,		02		ART UNIT	PAPER NUMBER	
, ,				1763		

DATE MAILED: 02/01/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

Advisory Action Before the Filing of an Appeal Brief

Application No.	Applicant(s)	
10/644,957	BEASE ET AL.	
Examiner	Art Unit	
Maureen G. Arancibia	1763	

	Maureen G. Arancibia	1763					
The MAILING DATE of this communication app	ears on the cover sheet with the	correspondence add	ress				
THE REPLY FILED 19 January 2006 FAILS TO PLACE THIS APPLICATION IN CONDITION FOR ALLOWANCE.							
 The reply was filed after a final rejection, but prior to or this application, applicant must timely file one of the foll places the application in condition for allowance; (2) a N (3) a Request for Continued Examination (RCE) in comfollowing time periods: 	on the same day as filing a Notice of lowing replies: (1) an amendment, a Notice of Appeal (with appeal fee) in	of Appeal. To avoid ab affidavit, or other evide a compliance with 37 (ence, which CFR 41.31; or				
a) \square The period for reply expires 3 months from the mailing date							
b) The period for reply expires on: (1) the mailing date of this Acevent, however, will the statutory period for reply expire later to Examiner Note: If box 1 is checked, check either box (a) or (b)	han SIX MONTHS from the mailing date of	of the final rejection.					
MONTHS OF THE FINAL REJECTION. See MPEP 706.07	(n).						
Extensions of time may be obtained under 37 CFR 1.136(a). The date obeen filed is the date for purposes of determining the period of extension CFR 1.17(a) is calculated from: (1) the expiration date of the shortened s above, if checked. Any reply received by the Office later than three mont earned patent term adjustment. See 37 CFR 1.704(b). NOTICE OF APPEAL	and the corresponding amount of the fee. statutory period for reply originally set in the	The appropriate extension final Office action; or (2)	n fee under 37 as set forth in (b)				
2. The Notice of Appeal was filed on A brief in con of filing the Notice of Appeal (37 CFR 41.37(a)), or any Since a Notice of Appeal has been filed, any reply must	extension thereof (37 CFR 41.37(e)), to avoid dismissal o	of the appeal.				
AMENDMENTS							
3. The proposed amendment(s) filed after a final rejection			because				
 (a) \overline{\overline) I E below);					
(c) They are not deemed to place the application in b appeal; and/or	•	educing or simplifying	the issues for				
(d)☐ They present additional claims without canceling	, -	ejected claims.					
NOTE: <u>See Continuation Sheet</u> . (See 37 CFR 1.	.116 and 41.33(a)).						
4. The amendments are not in compliance with 37 CFR 1		ompliant Amendment	(PTOL-324).				
5. Applicant's reply has overcome the following rejection(•						
 Newly proposed or amended claim(s) would be the non-allowable claim(s). 	allowable if submitted in a separate	, timely filed amendm	ent canceling				
 7. For purposes of appeal, the proposed amendment(s): a how the new or amended claims would be rejected is pr The status of the claim(s) is (or will be) as follows: 		vill be entered and an	explanation of				
Claim(s) allowed:							
Claim(s) objected to:							
Claim(s) rejected: <u>1-16</u> . Claim(s) withdrawn from consideration: <u>17-36</u> . AFFIDAVIT OR OTHER EVIDENCE							
 The affidavit or other evidence filed after a final action, because applicant failed to provide a showing of good a and was not earlier presented. See 37 CFR 1.116(e). 							
 The affidavit or other evidence filed after the date of filir entered because the affidavit or other evidence failed to showing a good and sufficient reasons why it is necessar 	overcome <u>all</u> rejections under appears and was not earlier presented.	eal and/or appellant fa See 37 CFR 41.33(d)(ils to provide a 1).				
10. ☐ The affidavit or other evidence is entered. An explanat REQUEST FOR RECONSIDERATION/OTHER							
11. The request for reconsideration has been considered by See Continuation Sheet.			ince because:				
12. ☐ Note the attached Information Disclosure Statement(s13. ☐ Other:). (PTO/SB/08 or PTO-1449) Paper	No(s)					

Marneer Harano: bi

Continuation of 3. NOTE: The proposed amendment to the independent claims to recite that the high-permittivity material is substantially free of Si raises a new issue that further limits the claims and would require further consideration and/or search. Also, the proposed amendment raises the issue of new matter, since there does not appear to be support in the original disclosure for the recitation that the high-permittivity material is substantially free of Si. It has been held that negative limitations recited to overcome prior art can be considered new matter, and that the mere absence of a positive recitation in the original specification is not basis for the exclusion of a feature. Ex Parte Grasselli et al. 231 USPQ 393.

Continuation of 11. does NOT place the application in condition for allowance because:

In regards to Applicant's argument against the obviousness-type double patenting rejection, the Examiner recognizes that the dry etching step recited in Claim 93 of co-pending application 10/670,795 ('795) is different from the wet etching step recited in the instant claims. For that reason, the secondary reference of U.S. Patent 6,818,553 to Yu et al. was relied on for the teaching of a wet etching step. As asserted in the rejection, it would have been obvious to one of ordinary skill in the art to make the etching step recited in Claim 93 of '795 a wet etching, as taught by Yu et al. (Column 3, Line 66 - Column 4, Line 10), in order to perform a selective etch that does not require masking of the substrate and does not damage other features of the substrate (ex. source/drain areas). Furthermore, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See In re Keller, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); In re Merck & Co., 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

Applicant's remaining arguments rely on the proposed amendment to the claims, which will not be entered.

PARVIZ HASSANZADEH SUPERVISORY PATENT EXAMINER